

# Supplementary Information

## Preparation of Monolayer MoS<sub>2</sub> Quantum Dots using Temporally Shaped Femtosecond Laser Ablation of Bulk MoS<sub>2</sub> Targets in Water

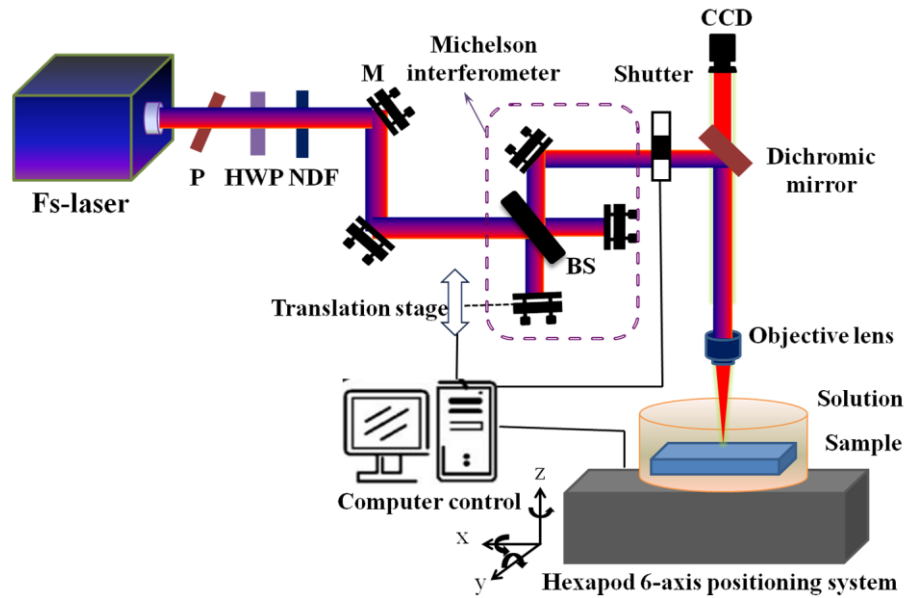
Bo Li<sup>1</sup>, Lan Jiang<sup>1,\*</sup>, Xin Li<sup>1</sup>, Peng Ran<sup>1</sup>, Pei Zuo<sup>1</sup>, Andong Wang<sup>1</sup>, Liangti Qu<sup>2</sup>, Yang Zhao<sup>2</sup>,  
Zhihua Cheng<sup>2</sup>, Yongfeng Lu<sup>3</sup>

<sup>1</sup>Laser Micro/Nano Fabrication Laboratory, School of Mechanical Engineering, Beijing Institute of Technology, Beijing, 100081, PR China

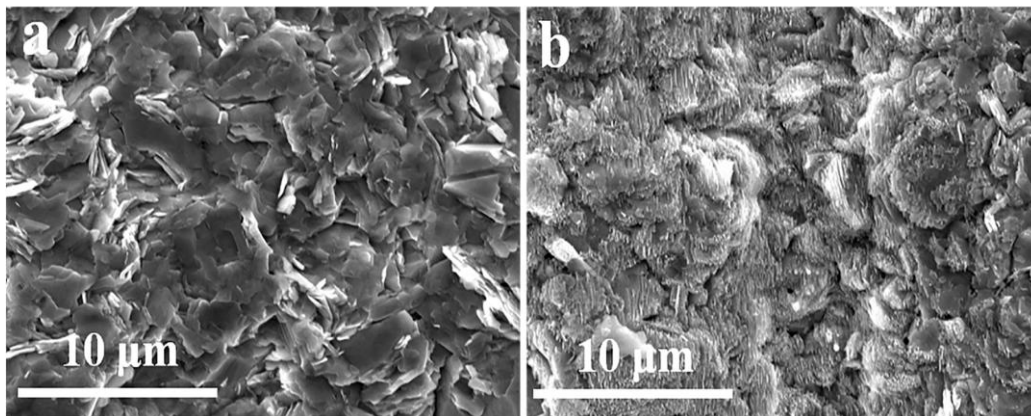
<sup>2</sup>Key Laboratory of Cluster Science, Ministry of Education, School of Chemistry, Beijing Institute of Technology, Beijing 100081, PR China

<sup>3</sup>Department of Electrical and Computer Engineering, University of Nebraska-Lincoln, Lincoln, NE 68588-0511, USA.

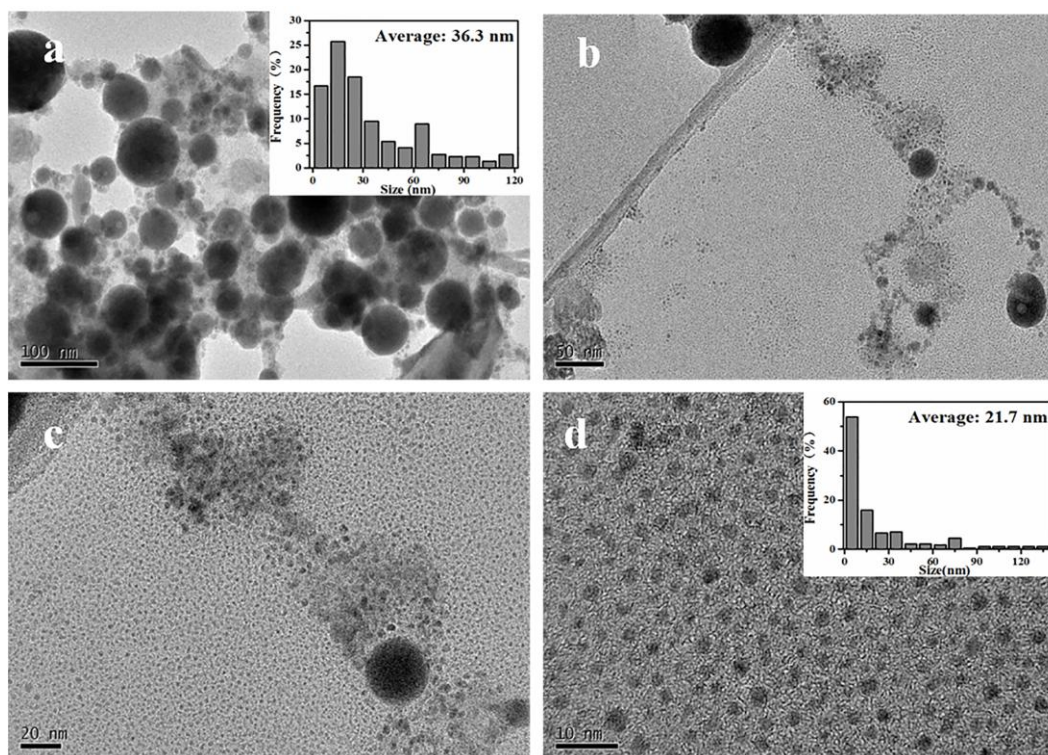
\**jianglan@bit.edu.cn*



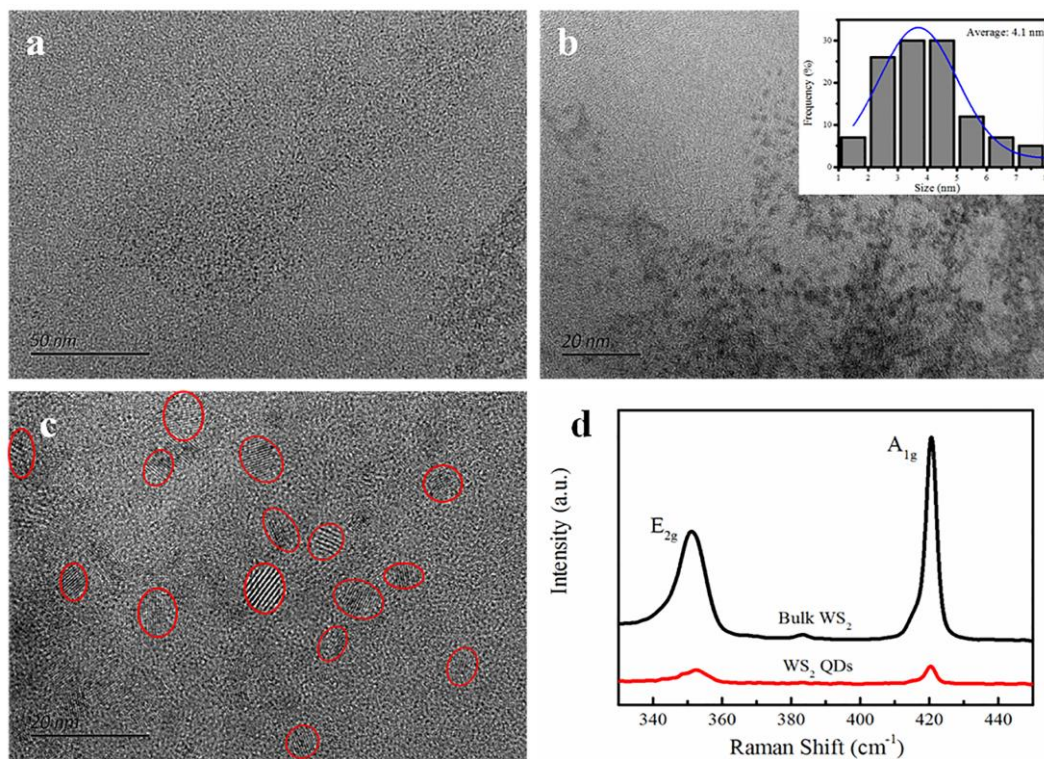
**Figure S1.** Schematic of the experimental setup for two-subpulse generation. P: polarizer; HWP: half-wave plate; NDF: neutral density filters; M: mirror; BS: beam splitter; CCD: charge coupled device.



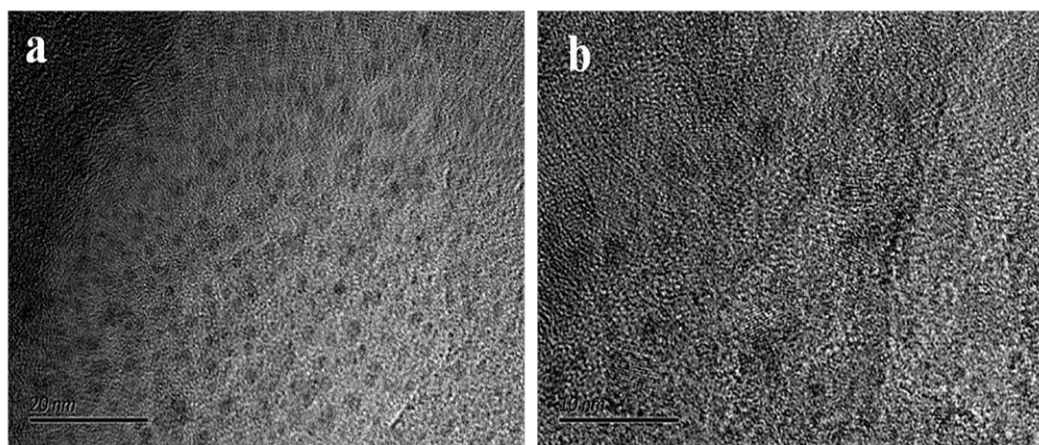
**Figure S2.** SEM images of the surface of original bulk MoS<sub>2</sub> target (a) before and (b) after femtosecond-laser temporally shaped two-subpulse train ablation in water.



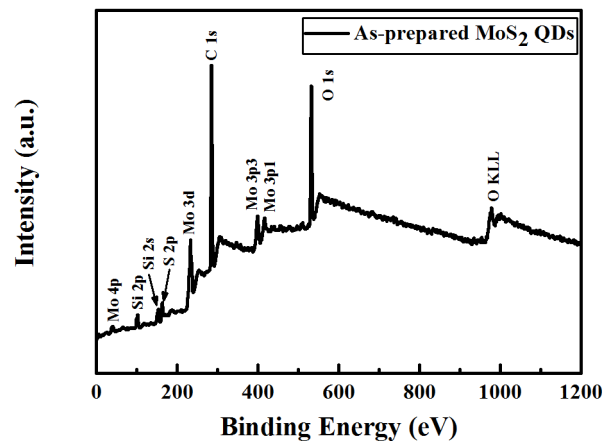
**Figure S3.** The TEM images corresponding to the morphology of MoS<sub>2</sub> nanomaterials in the aqueous solutions before centrifugation: (a) obtained by femtosecond laser single pulse ablation; (b), (c), and (d) obtained by temporally shaped femtosecond laser two-subpulse train ablation. The insert image of a and d show the size distribution. The scar bars are 100 nm, 50 nm, 20 nm, and 10 nm, respectively.



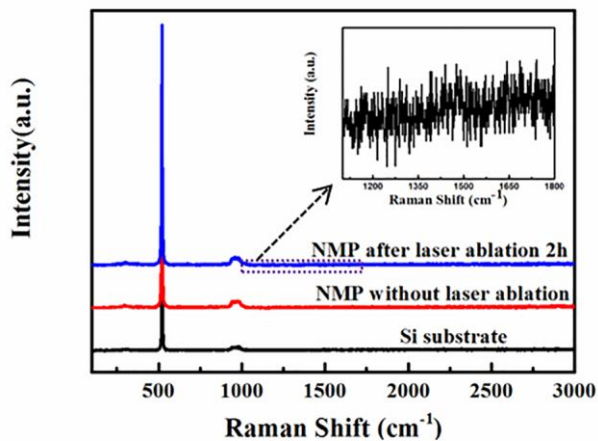
**Figure S4.** (a-c) TEM and HRTEM images of the as-prepared WS<sub>2</sub> QDs, the scale bars are 50 nm, 20 nm, and 20 nm, respectively. The inset in (b) is the size distribution of the WS<sub>2</sub> QDs. (d) The Raman spectrum of the bulk WS<sub>2</sub> and WS<sub>2</sub> QDs.



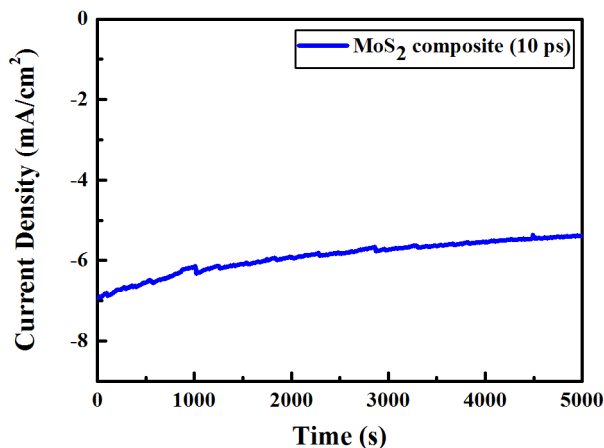
**Figure S5.** The TEM image of the as-prepared GQDs. The scale bars are 20nm and 10 nm, respectively.



**Figure S6.** The full spectrum of XPS survey of the as-prepared MoS<sub>2</sub> QDs.



**Figure S7.** The Raman spectra of the Si substrate, NMP solution without laser ablation, and NMP solution after laser ablation for 2h, respectively. And the inset image is the local magnification of the spectra of NMP solution after laser ablation for 2h.



**Figure S8.** The durability test of MoS<sub>2</sub> composites (composite of MoS<sub>2</sub> nanosheets, nanoparticles, and QDs obtained by temporally shaped femtosecond laser before centrifugation) with an applied voltage of -0.3 V vs RHE over 5000 seconds in 0.5 M H<sub>2</sub>SO<sub>4</sub>.

**Table S1.** Comparison of HERs performance with the MoS<sub>2</sub>-based HERs catalysts prepared by other typical synthesis methods.

Synthesis methods	Catalysts	Onset potential (V)	Overpotential (V)	Tafel slope (mV dec <sup>-1</sup> )	Refs.
<b>Precursors reaction</b>	Defect-free	-0.18	/	87	56
	MoS <sub>2</sub> NSs				
<b>Sonication combined with centrifugation</b>	MoS <sub>2</sub> NPs	-0.16	-0.2 (0.4 mA cm <sup>-2</sup> )	82	S2
<b>Liquid exfoliation</b>	MoS <sub>2</sub> QDs on NSs	-0.19	-0.4 (120 mA cm <sup>-2</sup> )	74	20
<b>Sonication combined with solvothermal</b>	MoS <sub>2</sub> QDs	-0.12	/	69	18
<b>Ultrasonication combined with centrifugation</b>	MoS <sub>2</sub> NPs	-0.09	-0.15 (0.92 mA cm <sup>-2</sup> )	69	45

<b>Ionic liquid assisted grinding exfoliation</b>	MoS <sub>2</sub> NDs	-0.09	-0.248 (10 mA cm <sup>-2</sup> )	61	9
<b>Electrochemical etching</b>	MoS <sub>2</sub> QDs	-0.21	/	60	22
<b>Hydrothermal</b>	MoS <sub>2</sub> QDs	-0.16	-0.4 (39 mA cm <sup>-2</sup> )	59	21
<b>Precursors reaction</b>	Defect-rich MoS <sub>2</sub> NSs	-0.12	-0.12 (13 mA cm <sup>-2</sup> )	50	56
<b>Chemical exfoliation</b>	MoS <sub>2</sub> NSs on graphite	/	-0.187 (10 mA cm <sup>-2</sup> )	43	53
<b>Solvothermal</b>	MoS <sub>2</sub> NPs on RGO	-0.1	/	41	S1
<b>Temporally shaped femtosecond-laser ablation</b>	MoS <sub>2</sub> composites	-0.14	-0.4 (36 mA cm <sup>-2</sup> )	66	This work

NSs: Nanosheets

NPs: Nanoparticles

NDs: Nanodots

RGO: Reduction graphene oxide

## References

- S1. Y. Li, H. Wang, L. Xie, Y. Liang, G. Hong and H. Dai, *J. Am. Chem. Soc.* **2011**, *133*, 7296.
- S2. T. Y. Wang, D. L. Gao, J. Q. Zhuo, Z. W. Zhu, P. Papakonstantinou, Y. Li, M. X. Li, *Chem.–Eur. J.* **2013**, *19*, 11939.